

Hydrogen Release from NH₃ in the Presence of BN Graphene: DFT Studies

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Abstract. Using density functional theory, we investigated the interaction of an NH₃ molecule with a pristine and antisite defected BN sheet (g-BN) in terms of energetic, geometric, and electronic properties. The adsorption energy of NH₃ on defected g-BN was calculated to be in the range of -0.70 to -2.46 eV, which is considerably more negative than that on the pristine sheet. It was found that the adsorption of NH₃ on the defected sheet may cause the release of an H₂ molecule. The electronic properties of the defected BN sheet were significantly changed after the adsorption process so that its HOMO/LUMO energy gap was changed from 3.31 to 3.60-4.97 eV. Moreover, the Fermi level of the defected sheet shifts to higher energies after the interaction, which results in reduced potential barrier of the electron emission for the sheet surface, enhancing the field emission because of the decreased work function.

Key words: Boron Nitride Nanosheet, Graphene-like, DFT, B3LYP, Ammonia.

Resumen. Usando la teoría de funcionales de la densidad investigamos la interacción de una molécula de NH₃ con sábanas de grafeno prístinas y con defectos anti-sitio BN (g-BN) en términos energéticos, geométricos y de propiedades electrónicas. La energía de absorción calculada de NH₃ en g-BN está en el rango de -0.70 a -2.46 eV, lo cual es considerablemente más negativo que en las sábanas prístinas. Se encontró que la absorción de NH₃ en las sábanas con defectos puede causar la liberación de una molécula de H₂. Las propiedades electrónicas de las sábanas con defectos BN muestran que hay carga significativa después del proceso de absorción, de modo que la diferencia de energía HOMO/LUMO varía de 3.31 a 3.60-4.97 eV. Por otra parte, el nivel de Fermi de las sábanas con defecto se mueve a energías de interacción más altas lo que resulta en barreras de energía potencial reducidas para la emisión de electrones desde la superficie de la sábana, incrementado el campo de emisión debido a la disminución de la función trabajo.

Palabras clave: Nano-sábanas con Boro y Nitrógeno, tipo grafeno, TDF, B3LYP, amonio.

Introduction

Depletion of fossil fuels as well as environmental concerns has led to widespread research for finding new and renewable energy sources. Hydrogen (H₂) has attracted great interest because of its high chemical energy content (at least three times larger than that of other chemical fuels), abundance, and non-polluting nature [1, 2]. Hydrogen economy offers an alternative to our dependence on fossil fuels and provides an environmentally clean source of energy. However, the application of hydrogen economy for practical applications requires efficient H₂ storage with high gravimetric and volumetric density [3]. Therefore, much research has been focused on hydrogen production from hydrogen storage materials such as CaH₂, LiH, NaBH₄, MgH₂, LiAlH₄, KBH₄, NaAlH₄, and NH₃ with superior catalyst systems [4, 5].

Ammonia contains 17.8 wt% hydrogen and stores 30% more energy by liquid volume than liquid hydrogen. Ammonia is the second largest synthetic commodity product of the world's chemical industry and the infrastructure for ammonia transportation, distribution, storage, and utilization is well-established [6]. It is also very important to note that NH₃ molecules are carbon free; there is no need for the purification of hydrogen produced by NH₃ decomposition because its by-product most often is N₂ that is benign. Ammonia can be used as an on-board carrier of hydrogen, where the latter can be released by NH₃ decomposition.

Ever since the discovery of carbon nanotubes (CNTs) [7], there have been significant research efforts to synthesize nanometer scale tubular forms of various materials and to study their properties [8-13]. A sheet of carbon atoms arranged in a two-dimensional hexagonal lattice is known as graphene. Graphene sheets can be transformed into various dimensional carbon materials by self-assembly and are thus the (2D) building blocks of many carbon materials [14-16]. Nevertheless, graphene usually suffers from various types of defect in atomic structures during its growth. A large number of experimental and theoretical studies have demonstrated that the existence of defects, such as Stone-Wales defects, vacancies, antisite, and pentagonal-octagon in graphene and nanotubes can drastically change the properties of these nanostructures [17-23]. Similar to graphene, graphene-like BN (g-BN) as a wide gap semiconductor, has been successfully fabricated by controlled energetic electron irradiation through a layer-by-layer sputtering process [24]. The g-BN has aroused extensive research interest because of its many intriguing properties such as high chemical stabilities, excellent mechanical properties, and high thermal conductivities [25-28]. Compared to their carbon counterparts, g-BN nanomaterials have much larger band gap, hence low electrical conductance. The surface of g-BN nanomaterials is intrinsically inert because of the large ionicity of the BN bond, making the chemical modification and practical processing of these materials difficult.

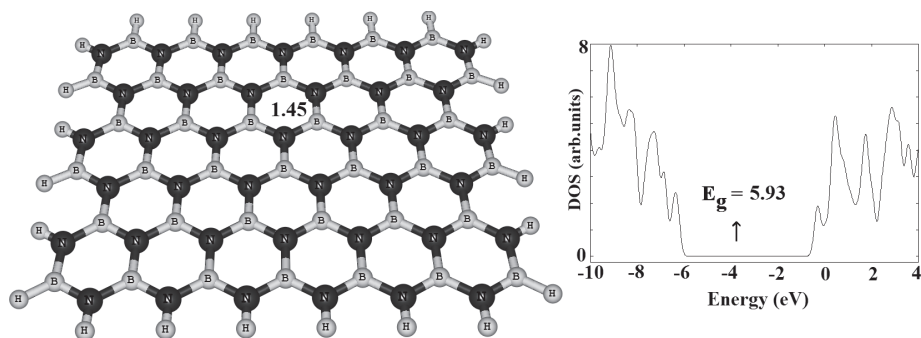


Fig. 1. Optimized structure of g-BN and its density of states (DOS) plot. Distance is in Å.

In the present work, the interaction of NH_3 with g-BN will be theoretically investigated based on analyses of structure, energies, electronic properties, etc. To this end, we have tried to find the answers of the following questions: (1) potential utility of g-BN as a H_2 generator from NH_3 ; (2) if not, what strategy can be applied to improve the reactivity of the g-BN toward NH_3 .

Computational Methods

A g-BN consisting of 36 boron and 36 nitrogen atoms was considered, whose end atoms were saturated with hydrogen atoms to avoid the boundary effects. The full geometry optimizations and property calculations on the pristine and antisite defected g-BN in the presence and absence of a NH_3 molecule were performed using three-parameter hybrid generalized gradient approximation with the B3LYP functional and the 6-31G basis set including the d-polarization function (denoted as 6-31G(d)) as implemented in the GAMESS suite of program [29]. GaussSum program [30] was used to obtain DOS results. In order to plot DOS plots, the orbital energies were set to be -10 to 4 eV and the full width at half maximum was 0.3 Å. The B3LYP density functional has been previously shown to reproduce experimental properties and has been commonly used for nanostructures [31-34]. It has also been demonstrated that the B3LYP provides an efficient and robust basis for calculations of III-V semiconductors by Tomić *et al.* [35], capable of reliably predicting both the ground state energies and the electronic structure. The adsorption energy (E_{ad}) of an NH_3 molecule on the g-BN is obtained using the following equation:

$$E_{\text{ad}} = E(\text{g-BN}/\text{NH}_3) - E(\text{g-BN}) - E(\text{NH}_3) + E_{\text{BSSE}} \quad (1)$$

where $E(\text{g-BN}/\text{NH}_3)$, $E(\text{NH}_3)$, and $E(\text{g-BN})$ are referred to the energies of the g-BN/ NH_3 complex, isolated NH_3 molecule, and the pristine or defected g-BN, respectively. E_{BSSE} is the energy of the basis set superposition error. The negative value of E_{ad} indicates the exothermic character of the adsorption. The canonical assumption for Fermi level (E_{FL}) is that in a molecule (at $T = 0$ K) it approximately is average of the HOMO-LUMO energy gap (E_g).

Results and discussion

NH_3 adsorption on the pristine g-BN

The optimized structure of the pristine g-BN is shown in Fig. 1, in which the lengths of B-N bonds are in the range of 1.42 - 1.48 Å, in good accordance with previous experimental and theoretical results [36]. Calculated density of states (DOS) plot shows that the g-BN is a semiconductor with the E_g of 5.93 eV (Fig. 1). In order to find minimum adsorption configurations, the NH_3 molecule was initially placed at different positions above a g-BN, on top of either boron or nitrogen atoms from its H or N atoms. After relax geometry optimization of initial guesses, only one stable NH_3 sheet was predicted (Fig. 2). *Other initial configurations have reoriented to this stable structure during the relax optimization.* In this configuration, the N atom of NH_3 forms a chemical bond with a B atom of the sheet (Fig. 2) with E_{ad} of -0.40 eV (Table 1). Our NBO calculations show that the hybridization of the B atom in the pure sheet and complex form is about $sp^{2.04}$ and $sp^{2.11}$, respectively. The adsorption of NH_3 on the B site of g-BN may be explained by the fact that the B site acts as a Lewis acid for the base of NH_3 . Calculated DOS plots (Fig. 2) show that the NH_3 adsorption through this configuration has no sensible effects on the electronic proper-

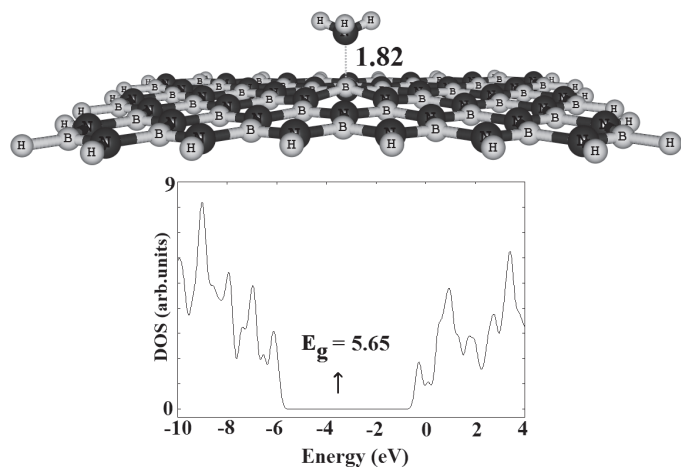


Fig. 2. Optimized structure of NH_3 adsorbed on the g-BN and its density of states plot (DOS). Distances are in Å.

Table 1. Calculated adsorption energy (E_{ad}), Fermi level energy (E_{F}), HOMO energies (E_{HOMO}), LUMO energies (E_{LUMO}), and HOMO-LUMO energy gap (E_{g}) of systems in eV at B3LYP/6-31G(d).

System	E_{ad}	E_{HOMO}	E_{F}	E_{LUMO}	E_{g}	$^{\text{a}}\Delta E_{\text{g}}(\%)$
g-BN	—	-6.28	-3.31	-0.35	5.93	—
NH ₃ /g-BN	-0.40	-5.97	-3.14	-0.32	5.65	-4.7

^aThe change of HOMO-LUMO gap of g-BN after adsorption.

Table 2. Calculated adsorption energy (E_{ad}), Fermi level energy (E_{F}), HOMO energies (E_{HOMO}), LUMO energies (E_{LUMO}), and HOMO-LUMO energy gap (E_{g}) of systems in eV (See Figs. 4, 6 and 7) at B3LYP/6-31G(d).

System	E_{ad}	E_{HOMO}	E_{F}	E_{LUMO}	E_{g}	$^{\text{a}}\Delta E_{\text{g}}(\%)$
Defected g-BN	—	-5.97	-4.31	-2.66	3.31	—
A	-1.71	-5.27	-3.07	-0.88	4.39	32.6
B	-0.70	-5.72	-3.92	-2.12	3.60	8.7
C	-0.87	-6.01	-3.97	-1.93	4.08	23.2
D	-2.46	-5.50	-3.01	-0.53	4.97	50.1
E	-1.35	-5.84	-3.93	-2.02	3.82	15.4

^aThe change of HOMO-LUMO gap of defected g-BN after adsorption.

ties of the sheet so that the E_{g} of the sheet has slightly decreased from 5.93 to 5.65 eV.

NH₃ adsorption on the antisite defected g-BN

Next, we have studied the interaction of a defected g-BN with an NH₃ molecule. Among various native defects, we have focused on boron antisite (B_{N}), in which a boron atom sits at the original nitrogen site, which is surrounded by three boron atoms, as shown in Fig. 3. The calculated bond length for the B-B bonds is 1.60 Å, which is much longer than the corresponding B-N bonds. Although the geometric structure of the g-BN is slightly distorted by substituting the N atom with the impurity of B (antisite defect), the optimized geometry for this defected system is perfectly planar. As a result, the B-B-B angle in the

defected g-BN is 120°, which is similar to B-N-B in the pristine sheet (almost 120°).

Subsequently, we have explored NH₃ adsorption on the defected site by locating the molecule above the impurity atom with different initial orientations including H or N atom of the molecule which is close to the B_{N} atom. We have also put the molecule on a B-B bond so that the H and N atoms are located on the top of the B atoms. However, after relax optimization of the initial structures, five stable configurations were obtained which have been shown in Figs. 4, and 5. We have divided the interactions, according to these minima structures, into two types: (I) chemisorption, in which the E_{ad} value is rather large in comparison with the pristine g-BN, and an insignificant change occurs in the geometrical parameters (configurations **A** and **B**, Fig. 4); and (II) dissociation, a very strong interaction that largely deforms the structure of the sheet and the molecule with bond cleavage and formation (configurations **C** and **D**, Fig. 4). Also, in one of the dissociation configurations, NH₃ molecule strongly interacts with the defected g-BN and one H₂ molecule was released (configuration **E**, Fig. 5). The E_{ad} , charge transfer, and E_{g} for all configurations have been summarized in Table 2.

Configuration **A** stands for the covalent bonding between the nitrogen atom of the NH₃ and the impure B_{N} atom of the sheet with the distance of 1.65 Å, and its corresponding calculated E_{ad} value is about -1.71 eV (Fig. 4A). The large E_{ad} of NH₃ on defected g-BN in this structure and the small distance between them reveal the chemical nature of the interaction. The B_{N} atom bonded to NH₃ molecule is lifted up, which, as the NBO analysis suggests, can be attributed to the change of their hybridization from sp^2 to nearly sp^3 . In addition, the length of B_{N} -B is increased from 1.60 Å to 1.67 Å after NH₃ adsorption. As shown in Fig. 4B, configuration **B** is the second most stable one for NH₃ chemisorption on defected g-BN system, in which the N atom of the molecule is close to a B atom of the sheet (which is the neighbor of B_{N}), with equilibrium distance of 1.70 Å and corresponding E_{ad} of -0.70 eV. Favorability of NH₃ adsorption on defected g-BN than on the pristine one can be explained by the fact that in defected g-BN the LUMO is mainly located on the B atoms of the defected site (Fig. 6). As a result, the HOMO of NH₃, located on the N atom,

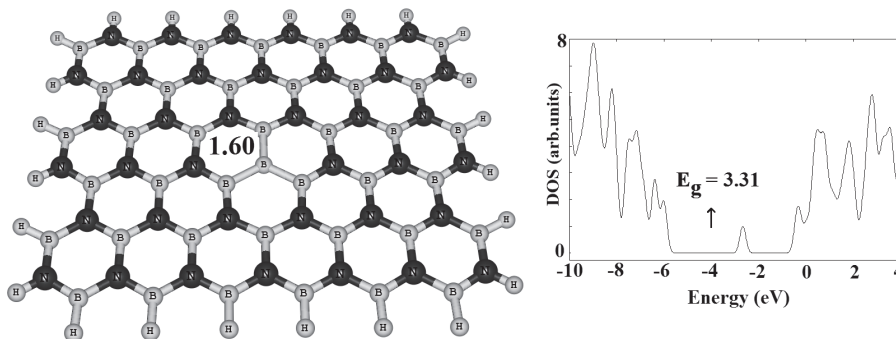


Fig. 3. Optimized structure of antisite defected g-BN and its density of states (DOS). Distance is in Å.

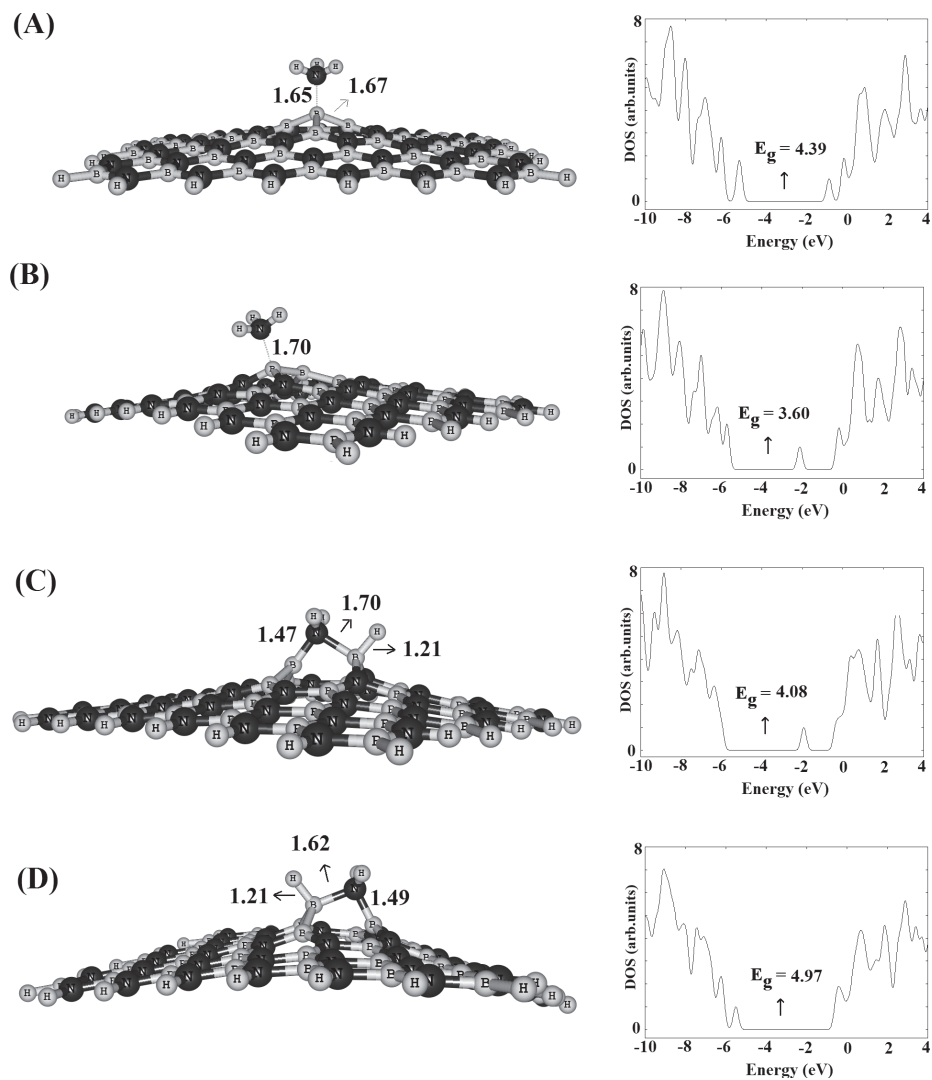


Fig. 4. Optimized structures for NH_3 chemisorption and dissociation on defected g-BN and their density of states (DOS). Distances are in Å.

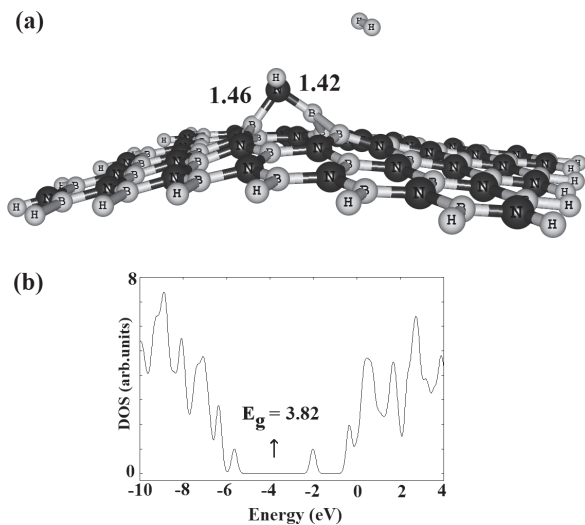


Fig. 5. (a) Configuration E, functionalized defected g-BN with NH_3 and (b) its density of states (DOS) after removal of released H_2 molecule. Distances are in Å.

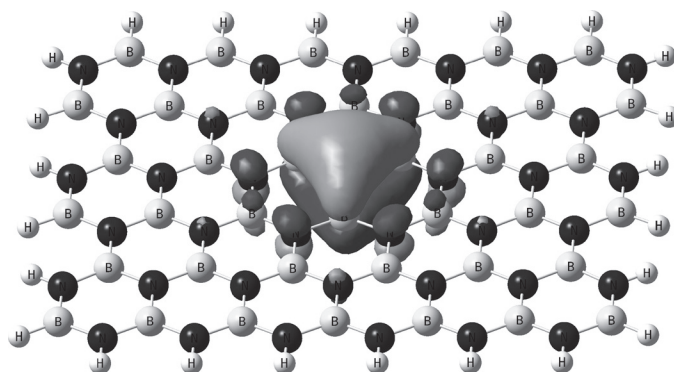


Fig. 6. The LUMO profile of antisite defected g-BN.

donates electrons preferentially to the LUMO centered on the B sites.

The calculated DOS of the defected g-BN is shown in Fig. 3, indicating that its E_g value is reduced to 3.31 eV, compared to the pristine g-BN. However, the defect forms an acceptor-like level, revealing that introducing a B_N antisite defect will create a p-type semiconductive material with increased conductivity. Interestingly, the DOS plot of configuration **A** shows a considerable change near the Fermi level, indicating that the electronic properties of the defected g-BN are very sensitive to the NH₃ adsorption. Valence level in this configuration is approximately similar to that of the defected sheet, while the conduction level significantly shifts downwards. As can be seen in Fig. 4A, the E_g value of the defected g-BN is dramatically increased from 3.31 eV to 4.39 eV (by about 34.3% change) in the adsorbed form, which would result in a change in the electrical conductivity of the defected sheet.

Subsequently, we have explored NH₃ dissociation by locating the molecule above the defected g-BN. The double-acceptor B-B antisite can interact with an NH₃ molecule strongly enough to break one of the N-H bonds. This type of interaction is analogous with the dihydrogen interaction in boron-doped carbon nanostructures [37], where a closed-shell H₂ is attracted by a single acceptor state of the carbon-substituted boron. We have identified two distinct configurations for the NH₃ dissociation, as shown in Fig. 4, namely **C** and **D**. In these configurations, N-H bond of the molecule is located on the top of the active B_N-B bond and NH₃ dissociation occurs. The main difference between these configurations is the orientation of -NH₂ and -H fragments of the NH₃. In both configurations, two new B-H and B-NH₂ bonds are formed with the lengths of 1.21 Å (1.21 Å) and 1.47 Å (1.49 Å), respectively. As a result, the E_{ad} of NH₃ on the sheet in configuration **D** (-2.46 eV) is remarkably more than that of the configuration **C** (-0.87 eV).

Surface modification is a commonly used method to tailor the physical and chemical properties of BN nanostructures. However, low chemical reactivity of the surface of g-BN means that the chemical modification of the structure is much more difficult than that of the graphene. Calculated DOS plots for configurations **C** and **D** have been shown in Fig. 5, indicating that the NH₃/defected g-BN complexes of configurations **C** and **D** attain E_g values of 4.08 and 4.97 eV, respectively, while E_g of the defected g-BN is about 3.31 eV (Fig. 3). It can be

therefore concluded that the modification of the defected g-BN by NH₃ molecule obviously changes the electrical properties of the sheet. Theoretical investigations have shown that introducing adsorbates on graphene surface might effectively modify the field emission properties of the material [38], which is essential to estimate the potential for designing efficient field emission displays. As shown in Table 2, not only the E_g of the defected g-BN has been changed, but also the E_{FL} has increased from -4.31 to -3.07 eV in configuration **A**. This phenomenon leads to a decrement in the work function which is important in field emission applications. The work (Φ) function can be found by :

$$\Phi = -eV - E_{FL} \quad (2)$$

where $-e$ is the charge of an electron, V is the electrostatic potential in the vacuum nearby the surface, and E_F is the energy of Fermi level. The work function is thus defined as the work required to remove an electron from the material to a state at rest in the vacuum nearby the surface. The decrement in the work function indicates that the field emission properties of the defected g-BN are facilitated after the adsorption of the NH₃ molecules.

Fig. 5 shows the chemical functionalization of the defected g-BN by NH₃. In this configuration, -NH fragment has diffused into the defected site from its N atom, so that two new B_N-N and B-N bonds are formed with the bond lengths of 1.42 and 1.46 Å, respectively. Interestingly, an H₂ molecule in this configuration has escaped from the sheet of defected g-BN. In this configuration (**E**), the E_{ad} value is about -1.35 eV, somewhat weaker than that of **C** and **D** configurations. We think that the more positive value of E_{ad} in this configuration can be attributed to the large deformation of NH₃ and also the sheet after the adsorption process. The results indicate that our proposed system may be a promising material for hydrogen storage. We also calculated the barrier energy for this process. Transition state structure is shown in Fig. 7, which has been optimized using the Synchronous Transit-Guided Quasi-Newton Method. The calculation shows that releasing an H₂ molecule needs the reaction process to overcome an energy barrier of 0.65 eV, which is relatively large. Thus, we think that these reactants may need to be heated to higher than room temperature to surmount this barrier energy. Also, our calculation shows that

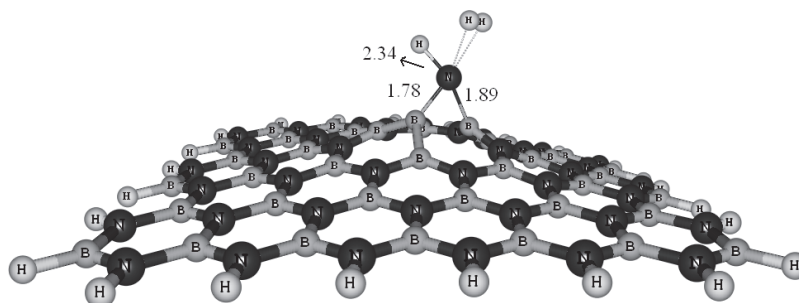


Fig. 7. Structure transition state for NH₃ dissociation on the antisite-defected g-BN. Distances are in Å.

Table 3. Calculated adsorption energy (E_{ad}), Fermi level energy (E_F), HOMO energies (E_{HOMO}), LUMO energies (E_{LUMO}), and HOMO-LUMO energy gap (E_g) of the systems in eV at B3LYP/6-311 + G(d).

System	E_{ad}	E_{HOMO}	E_F	E_{LUMO}	E_g	$^a\Delta E_g(\%)$
g-BN	—	-6.21	-3.25	-0.30	5.91	—
NH ₃ /g-BN	-0.33	-5.92	-3.14	-0.30	5.62	-1.9

^aThe change of HOMO-LUMO gap of g-BN after adsorption.

Table 4. Calculated adsorption energy (E_{ad}), Fermi level energy (E_F), HOMO energies (E_{HOMO}), LUMO energies (E_{LUMO}), and HOMO-LUMO energy gap (E_g) of systems in eV at B3LYP/6-311 + G(d) (See Figs. 4, 6 and 7).

System	E_{ad}	E_{HOMO}	E_F	E_{LUMO}	E_g	$^a\Delta E_g(\%)$
Defected g-BN	—	-5.91	-4.26	-2.62	3.29	—
A	-1.62	-5.25	-3.04	-0.83	4.42	34.3
B	-0.65	-5.65	-3.87	-2.10	3.55	7.9
C	-0.80	-5.98	-3.94	-1.90	4.08	24.0
D	-2.34	-5.46	-2.98	-0.51	4.95	50.4
E	-1.33	-5.80	-3.89	-1.99	3.81	15.8

^aThe change of HOMO-LUMO gap of defected g-BN after adsorption.

energy of 4.68 eV is needed to remove the -NH from the g-BN which is very high. We believe that the large energy is because of high instability of free -NH group. In our opinion, removal of this radical might be facilitated by using an auxiliary chemical group which needs more research.

For further investigation of the electronic properties of this new material, we have removed NH₃ molecule from the surface of g-BN and full relax optimization was performed. As shown in Fig. 5, the DOS of the NH-functionalized g-BN has a change near the conduction level compared to that of the defected g-BN, so that the LUMO energy shifts from -2.66 eV to -2.02 eV. In this structure, the E_g of the defected g-BN is increased to 3.82 eV (with 15.4% change) in the functionalized form. Our results have already provided an important insight into the difference in behavior of the pristine and antisite defected g-BN towards NH₃ adsorption and dissociation. Thus, we believe that introducing an antisite defect in g-BN can be a good strategy for improving the H₂ production by NH₃, which cannot be released by the pristine g-BN.

Finally, we have repeated our calculations with a larger basis set or a larger sheet. To this end, a g-BN consisting of 72 boron and 72 nitrogen atoms was considered. Our results show that E_g of systems slightly decreased in the range of 0.06 and 0.11 eV. The change of E_{ad} is in the range of 0.01-0.04 eV which is negligible. Once again calculation on the former sheet was repeated by using B3LYP with 6-311 + G(d). The results (Tables 3 and 4) indicates that absolute values of calculated parameter slightly changed in comparison to 6-31G(d) basis set (Tables 1 and 2).

Conclusion

The geometric structures and electronic properties of the pristine and antisite defected g-BN in the presence and absence of an adsorbed NH₃ molecule have been explored using density functional theory. It was found that the NH₃ molecule weakly interacts with the pristine g-BN, but it presents much higher reactivity towards the antisite defected g-BN. E_{ad} of NH₃ on defected g-BN was calculated to be in the range of -0.70 to -2.46 eV. It suggests that the antisite defected g-BN can be a promising surface for dissociation of NH₃ for chemical hydrogen storage. Also, the work function of the defected sheet is reduced after the interaction, resulting in reduced potential barrier of the electron emission for the sheet surface, hence enhancing the field emission.

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